

Course code	Course Name	L-T-P-Credits	Year of Introduction
ME474	Micro and Nano Manufacturing	3-0-0-3	2016
Prerequisite: Nil			
Course Objectives <ol style="list-style-type: none"> 1. To give awareness of different techniques used in micro and nano manufacturing 2. To give in-depth idea of the conventional techniques used in micro manufacturing 3. To introduce Non-conventional micro-nano manufacturing and finishing approaches 4. To introduce Micro and Nanofabrication Techniques and other processing routes in Micro and nano manufacturing 5. To know different techniques used in Micro Joining and the metrology tools in micro and nano manufacturing. 			
Syllabus Introduction to Precision engineering- Bulk micromachining – Micro-energy -Carbon Nanotubes - Molecular Logic Gates and Nanolevel Biosensors - Conventional Micro Machining - Non-conventional micro-nano manufacturing and finishing approaches - Micro and Nano Finishing Processes - Micro and Nanofabrication Techniques - Micro Joining - Characterization and metrology tools.			
Expected outcome The students will <ol style="list-style-type: none"> 1. get an awareness of different techniques used in micro and nano manufacturing. 2. get in-depth idea of the conventional techniques used in micro manufacturing. 3. become aware about non-conventional micro-nano manufacturing and finishing approaches. 4. get awareness on micro and nano finishing processes. 5. understand micro and nanofabrication techniques and other processing routes in micro and nano manufacturing. 6. know about different techniques used in micro joining and the metrology tools in micro and nano manufacturing. 			
References: <ol style="list-style-type: none"> 1. Mark. J. Jackson, Micro and Nano-manufacturing, Springer, 2006. 2. Mark. J. Jackson, Micro-fabrication and Nano-manufacturing - Pulsed water drop micromachining CRC Press 2006. 3. Nitaigour Premchand Mahalik, Micro-manufacturing and Nanotechnology, 2006. 4. V.K.Jain, Micro-manufacturing Processes, CRC Press, 2012. 			
Course Plan			
Module	Contents	Hours	End Sem. Exam. Marks
I	Introduction to Precision engineering, macro milling and micro drilling, Micro-electromechanical systems – merits and applications, Micro phenomenon in Electro-photography – applications	1	15%

	Introduction to Bulk micromachining, Surface micromachining-steps, Micro instrumentation – applications, Micro Mechatronics, Nanofinishing – finishing operations.	1	
	Laser technology in micro manufacturing- Practical Lasers, application of technology fundamentals	1	
	Introduction to Micro-energy and chemical system (MECS), Space Micro-propulsion, e-Beam Nanolithography – important techniques, Introduction to Nanotechnology	1	
	Carbon Nano-tubes – properties and structures, Molecular Logic Gates and Nano level Biosensors - applications	1	
II	Introduction to mechanical micromachining, Micro drilling – process, tools and applications	1	15%
	Micro turning- process, tools and applications, Diamond Micro turning – process, tools and applications	1	
	Micro milling and Micro grinding – process, tools and applications	1	
	Micro extrusion- process and applications	1	
	micro bending with Laser	1	
	Nano- Plastic forming and Roller Imprinting	1	
FIRST INTERNAL EXAMINATION			
III	Introduction to Non-conventional micro-nano manufacturing	1	15%
	Process, principle and applications – Abrasive Jet Micro Machining, WAJMM	1	
	Micro EDM, Micro WEDM, Micro EBM – Process principle, description and applications	1	
	Micro ECM, Micro LBM - Process principle, description and applications	1	
	Focused ion beams - Principle and applications	1	
IV	Introduction to Micro and Nano Finishing Processes	1	15%
	Magnetorheological Finishing (MRF) processes, Magnetorheological abrasive flow finishing processes (MRAFF) – process principle and applications	1	
	Force analysis of MRAFF process,	1	
	Magnetorheological Jet finishing processes	1	
	Working principle and polishing performance of MR Jet Machine	1	
	Elastic Emission Machining (EEM) – machine description, applications	1	
	Ion Beam Machining (IBM) – principle, mechanism of material removal, applications	1	
	Chemical Mechanical Polishing (CMP) – Schematic diagram, principle and applications	1	
SECOND INTERNAL EXAMINATION			
V	Introduction to Micro Fabrication: basics, flowchart, basic chip	1	20%

	making processes		
	Introduction to Nanofabrication, Nanofabrication using soft lithography – principle, applications – Examples (Field Effect Transistor, Elastic Stamp)	1	
	Manipulative techniques – process principle, applications	1	
	Introduction to Carbon nano materials – CN Tubes	1	
	CN Tubes – properties and applications	1	
	CN Tube Transistors – Description only	1	
	Diamond - Properties and applications	1	
	CVD Diamond Technology	1	
	LIGA Process	1	
V1	Laser Micro welding – description and applications, Defects	1	20%
	Electron Beam Micro-welding – description and applications	1	
	Introduction to micro and nano measurement, defining the scale, uncertainty	1	
	Scanning Electron Microscopy – description, principle	1	
	Scanning White-light Interferometry – Principle and application	1	
	Optical Microscopy – description, application	1	
	Scanning Probe Microscopy, scanning tunneling microscopy- description, application	1	
	Confocal Microscopy - description, application	1	
	Introduction to On-Machine Metrology	1	
	END SEMESTER EXAMINATION		

Question Paper Pattern

Maximum marks: 100

Time: 3 hrs

The question paper should consist of three parts

Part A

There should be 2 questions each from module I and II

Each question carries 10 marks

Students will have to answer any three questions out of 4 (3x10 marks =30 marks)

Part B

There should be 2 questions each from module III and IV

Each question carries 10 marks

Students will have to answer any three questions out of 4 (3x10 marks =30 marks)

Part C

There should be 3 questions each from module V and VI

Each question carries 10 marks

Students will have to answer any four questions out of 6 (4x10 marks =40 marks)

Note: Each question can have a maximum of four sub questions, if needed.